ELECTRONIC SUPPORTING INFORMATION (ESI)

Anodic formation of high aspect ratio, self-ordered Nb₂O₅ nanotubes Wei Wei, Kiyoung Lee, Santosh Shaw, Patrik Schmuki*

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Experimental Details

For anodization experiments we used niobium foils (0.125 mm thickness, 99.9% purity, Advent). They were degreased by sonicating in ethanol for 10 min, were then rinsed with deionized water (DI) and dried in a nitrogen stream. The electrolytes were prepared from glycerol (99% purity, containing less than 0.5 wt. % of H₂O) mixed with different amounts of NH₄F (0.2 M~0.6 M) and different water additions (0, 5 %, 10 %, 20 %, 50% vol. of DI water). All electrolytes were prepared from reagent grade chemicals (Sigma-Aldrich). All anodization treatments were carried out at room temperature for 2 hours using a three-electrode-system as described previously¹. We use a platinum flag (2.25 cm²) at a distance of 2cm from the working electrode as the counter electrode and a platinum wire as the quasi-reference electrode. The potentials reported in the manuscript therefore represent V vs. Pt.

During the anodization process, the voltage was ramped from open circuit potential to the final potential with a sweep rate of 500 mV s⁻¹ and then held at the final potential for 2 hours. After anodization, samples were immersed in ethanol for 1 hour to remove remnants of electrolyte and then left to dry in air. Some samples were thermally annealed at 550°C in N₂ atmosphere for 2 hours to crystallize the formed oxide layers.

In order to characterize the morphology of the obtained anodic oxide films, a field-emission scanning microscope (Hitachi FE-SEM S4800) and a transmission electron microscopy (Philips CM 30T/STEM

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microscope) were used. Cross-sectional measurements were carried out on mechanically cracked samples. X-ray diffractometry (XRD) was employed for structural characterization of the as-formed and annealed anodic oxide layers at a grazing angle of 1^{0} , using a X-ray diffractometer (Philips X'pert MPD PW3040 with a Panalytical X'celerator detector) with graphite monochromized Cu K α radiation (wavelength 1.54056 Å). Characterization of the chemical composition of the formed layers was carried out using X-ray photoelectron spectrometer (XPS, PHI 5600), using Al 2 mm K α monochromatic radiation (1486.6 eV; 300 W) as the excitation source.



Figure S1 SEM cross-sectional views of the anodic oxide films formed by anodization of Nb in the 0.4M NH₄F containing glycerol electrolyte under different voltages: (a) 10 V, (b) 30 V, (c) 40 V. (d) Current density transients recorded during the anodization of Nb in 0.4M NH₄F containing glycerol electrolytes at different voltages.

Reference

1. J. M. Macak, H. Tsuchiya, L. Taveira, S. Aldabergerova, P. Schmuki, *Angew. Chem. Int. Ed.*, 2005, **44**, 7463.